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journal homepage: www.elsevier.com/locate/msebEnhanced photovoltaic properties of eosin-Y sensitized solar cells using nanocrystalline N-doped TiO₂ photoanode filmsM.T. Sarode^{a,*}, Umesh T. Nakate^b, S.U. Ekar^{c,1}, Yogesh T. Nakate^d, S.R. Jadhkar^e, B.B. Kale^f, K.C. Mohite^g, Y.B. Khollam^{h,1}^a Radhakali Kale Mahila Mahavidyalaya, Toranapur, Ahmednagar 414007, Maharashtra, India^b Department of Polymer-Matrix Science and Technology, Jeonbuk National University (JNU), Jeonju-9, Jeonbuk, Korea, Republic of Korea^c Department of Physics, Bhalasaheb Ghosh College, Sangli, Pune 411022, Maharashtra, India^d Department of Electronics, K.J.S.O.M.M. University, Jalgaon 425001, Maharashtra, India^e School of Energy Studies, Department of Physics, Savitribai Phule Pune University, Pune 411007, Maharashtra, India^f Center for Materials for Electronics Technology, Panchawati, Off. Pashan Road, Pune 411006, Maharashtra, India^g Chaudhari Yashwantrao Kore College, Shikar, Pune 412210, Maharashtra, India

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ABSTRACT

Herein, the photovoltaic properties of Eosin-Y dye-sensitized N-doped TiO₂ photoanodes are demonstrated. The Doctor Blade method derived N-doped TiO₂ photoanodes were obtained from powders prepared by using hydrolysis at different Ti/N ratios followed by annealing at 400 °C/4h. The detailed SEM, TEM, XRD, Faman, and XPS analyses were performed. The N dopant-induced lattice disorder effects and midgap electronic states arising from O vacancies due to replacement of O by N leads to the narrowing energy band gap, E_g. XPS E.L. confirmed material purity and N-incorporation in TiO₂ matrix through O-Ti-N linkage leading to dopant-induced strain. The photovoltaic properties: V_{OC} = 653 mV, J_{SC} = 11 mA/cm², FF = 51.28 %, η = 1.73 % obtained for photoanode made with 1:15 M ratio can be linked with formation of mesochannel structure leading to substantial porosity for optimum visible light absorption and dye absorption due to N doping in O-Ti-O lattice.

1. Introduction

O'Regan and Grätzel have created a new generation of solar cells namely dye sensitized solar cell (DSSC) in 1991 [1]. This new generation has taken extensive attention over the last two-three decades due to its potential advantages such as cheaper compared to commercial solar cells based on silicon, easy to fabricate [1–2] and high photo-conversion efficiencies [3]. For photochemical energy conversion processes, TiO₂ is a widely used material. However, due to the wide band gap: 3.0 eV and 3.2 eV for rutile and anatase TiO₂ phases respectively, it requires ultraviolet (UV) light for the excitations of electron-hole pairs. Hence, only 6–8 % of the solar band radiations coming under the UV light range is accessible to pure TiO₂. It puts a limit on the applicability of TiO₂ towards the efficient conversion of solar energy to electrical energy. Hence, in order to increase the visible light absorption, narrowing of the band gap of TiO₂ at a desirable level is required. This goal can be achieved through doping of TiO₂ by cationic / anionic impurities [4]. It

increases the visible light absorption through the generation of band gap states induced by dopant impurities. A number of research articles have highlighted the advantages of TiO₂ [1–3], wherein TiO₂ nanoparticles showed the following properties: (i) improved surface area leading to more light exposure and simplifying the surface photochemical reactions, (ii) improved photoinduced charge transport [5–6] required for harvesting-donating of photoinduced electrons and (iii) profound change in the photoelectrochemical properties due to the absence of depletion layer development on the surface. These effects have benefited the N-doped TiO₂ system. In recent years, N-doped TiO₂ nanoparticles have received the considerable interest due to their novel properties and advantages of size in nanometric range [7–12]. There is great progress in metal (Zn, Ta, La etc.) [13–16] and non-metal (N, B etc.) doped TiO₂ materials. The N-doped TiO₂ materials are found to be suitable for photoanodes in DSSC application [17–22]. However, very few reports indicating the photovoltaic characteristics of DSSCs fabricated by using the N-doped TiO₂ photoanode films obtained by the Doctor Blade

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